

Electronic Patent Application Fee Transmittal

Application Number:	10687713			
Filing Date:	17-Oct-2003			
Title of Invention:	Surface treated low-k dielectric as diffusion barrier for copper metallization			
First Named Inventor:	Kuei-Wu Huang			
Filer:	Richard A. Paikoff/Donna Winkler			
Attorney Docket Number:	N1085-00184 [TSMC2002-132			
Filed as Large Entity				
Utility Filing Fees				
Description	Fee Code	Quantity	Amount	Sub-Total in USD(\$)
Basic Filing:				
Pages:				
Claims:				
Miscellaneous-Filing:				
Petition:				
Patent-Appeals-and-Interference:				
Post-Allowance-and-Post-Issuance:				
Extension-of-Time:				

Description	Fee Code	Quantity	Amount	Sub-Total in USD(\$)
Miscellaneous:				
Request for continued examination	1801	1	790	790
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